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Alty. Okt. No. AMAT/6452.P1/CPI/L/B/PJS

IN THE CLAIMS:

Please amend the claims as follows:

1. (Original) A shutter disk for covering a substrate support in a physical vapor deposition chamber comprising:

a disk body defined by an outer edge, a top surface extending to the outer edge and a lower surface disposed opposite the top surface, wherein the lower surface further comprises:

- a center pad extending from the lower surface;
- a recess formed in the center pad coaxially with the disk body; and
- a lip extending from the lower surface proximate the outer edge, the lip extending below the center pad.
- 2. (Original) The shutter disk of claim 1, wherein the center pad is perpendicular to a center axis of the disk body.
- 3. (Original) The shutter disk of claim 2, wherein the center pad has a surface finish better than about 32 RMS.
- 4. (Original) The shutter disk of claim 1, wherein the disk body is fabricated from stainless steel or titanium.
- 5. (Original) The shutter disk of claim 4, wherein the recess further comprises outward flaring sidewalls.
- 6. (Original) A shutter disk for covering a substrate support in a physical vapor deposition chamber comprising:
- a disk body having a center axis and defined by an outer edge, a top surface extending to the outer edge and a lower surface disposed opposite the top surface, wherein the lower surface further comprises:
 - a center pad extending from the lower surface;

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a blind hole having outwardly flaring sides formed in the center pad along the center axis of the disk body;

a lip extending from the lower surface proximate the outer edge, the lip extending below the center pad to a lip face that is parallel to the center pad; and

an annular recess formed in the lower surface between the center pad and lip.

- 7. (Original) A physical vapor deposition chamber comprising:
 - a chamber body having sidewalls and a bottom defining a process volume;
 - a substrate support;
 - a housing sealingly coupled to the chamber body;

a disk body having a center axis and defined by an outer edge, a top surface extending to the outer edge and a lower surface disposed opposite the top surface, wherein the lower surface further comprises a center pad extending from the lower surface and a lip extending from the lower surface proximate the outer edge, the lip extending below the center pad;

a robot having a blade adapted to move the disk body between the housing and chamber body; and

an alignment feature disposed between the center pad and the blade, wherein the alignment feature engages the disk body along the center axis.

- 8. (Original) The chamber of claim 7 further comprising: at least a first sensor disposed adjacent to the housing and orientated to detect the presence of a portion of at least one of the disk body or blade within the housing.
- 9. (Original) The chamber of claim 7, wherein the center pad is perpendicular to the center axis of the disk body.
- 10. (Original) The chamber of claim 7, wherein the center pad has a surface finish better than about 32 RMS.

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- 11. (Original) The chamber of claim 7, wherein the disk body is fabricated from stainless steel or titanium.
- 12. (Original) The chamber of claim 7, wherein the robot blade is fabricated from titanium.
- 13. (Currently Amended) The chamber of claim 7, wherein the robot blade further comprises:
 - a raised pad configured to having support the center pad disposed thereon.
- 14. (Original) The chamber of claim 13, wherein the alignment feature comprises: a post engaging the raised pad and center pad.
- 15. (Currently Amended) The chamber of claim 14, wherein the post is coupled to the raised pad and mates with a blind hole formed in the center pad.
- 16. (Original) The chamber of claim 15, wherein the blind hole has a tapered sidewall.
- 17. (Original) The chamber of claim 7, wherein the robot blade further comprises: a groove formed therein having a portion of the lip mated therewith, the groove configured to maintain a gap between the robot blade and lip of the disk body.
- (Original) The processing chamber of claim 7 further comprising:
 a first window formed in the housing; and
- a first sensor positioned to view at least one of the disk body or robot blade through the window.
- 19. (Original) The processing chamber of claim 18 further comprising: a second sensor disposed adjacent to the housing and orientated to detect the presence within the housing of the shutter mechanism.

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- 20. (Original) The chamber of claim 19, further comprising:
- a third sensor disposed adjacent to the first and second sensors, the third sensor orientated to detect the presence of the blade within the housing.
- 21. (Original) The processing chamber of claim 7, wherein the housing further comprises:

an emitter disposed proximate the first window; and

- a receiver disposed proximate a second window disposed in the housing opposite the first window, the receiver linearly aligned with the emitter, first window and second window.
- 22. (Currently Amended) A physical vapor deposition chamber comprising:
- a chamber body having sidewalls and a bottom defining a process volume, wherein a slot is formed through one of the sidewalls;
- a shutter disk mechanism at least partially disposed in the process volume and having a robot blade and a shutter disk engaged by an alignment feature, the alignment feature disposed along a center axis of the shutter disk, wherein the shutter disk has a lower surface comprising:
 - a center pad near the center axis; and
 - a lip extending along an outer edge of the shutter disk and extending below the center pad; a slot formed through one of the sidewalls; and a housing sealingly coupled to the chamber body.
- 23. (Original) The chamber of claim 22, further comprising: at least a first sensor disposed adjacent to the housing and orientated to detect the presence of a portion of the shutter disk mechanism within the housing.
- 24. (Original) The chamber of claim 23, wherein the center pad is perpendicular to the center axis of the disk body and parallel to the lip.

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- 25. (Currently Amended) The chamber of claim 23, wherein the disk body and robot blade are fabricated <u>from</u> materials having substantially similar or identical coefficients of thermal expansion.
- 26. (Currently Amended) The chamber of claim 23, wherein the robot blade further comprises:
 - a raised pad having configured to support the center pad disposed thereon.
- 27. (Original) The chamber of claim 26, wherein the alignment feature comprises: a post engaging the raised pad and center pad.
- 28. (Currently Amended) The chamber of claim 27, wherein the post is coupled to the raised pad and mates with a blind hole formed in the center pad.
- 29. (Original) The chamber of claim 28, wherein the blind hole has a tapered sidewall.
- 30. (Original) The chamber of claim 23, wherein the robot blade further comprises:
- a groove formed therein having a portion of the lip mated therewith, the groove configured to maintain a gap between the robot blade and lip of the disk body.
- 31. (Currently Amended) A method for positioning a shutter disk within a physical vapor deposition chamber having a substrate support, comprising: spacing a shutter disk vertically from a substrate support; moving a robot blade between the substrate support and the shutter disk[[,]]; and

engaging the shutter disk and the robot blade by coupling a post disposed on the robot blade with an alignment feature disposed along a center axis of the shutter disk.

32. (Original) The method of claim 31 further comprising:

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setting the shutter disk on a perimeter of the substrate support wherein center portions of the shutter disk and substrate support remain in a spaced-apart relation.

Please add new claims 33-35 as follows:

- 33. (New) A physical vapor deposition chamber comprising:
 - a chamber body having sidewalls and a bottom defining a process volume;
- a shutter disk mechanism at least partially disposed in the process volume and having a robot blade and a shutter disk engaged by an alignment feature, the alignment feature disposed along a center axis of the shutter disk;
 - a slot formed through one of the sidewalls;
 - a housing sealingly coupled to the chamber body; and
- at least a first sensor disposed adjacent to the housing and orientated to detect the presence of a portion of the shutter disk mechanism within the housing.
- 34. (New) The chamber of claim 33, wherein the robot blade further comprises:
- a groove formed therein having a portion of the lip mated therewith, the groove configured to maintain a gap between the robot blade and lip of the disk body.
- 35. (New) A method for positioning a shutter disk within a physical vapor deposition chamber having a substrate support, comprising:

spacing a shutter disk vertically from a substrate support;

moving a robot blade between the substrate support and the shutter disk;

engaging the shutter disk and the robot blade with an alignment feature disposed along a center axis of the shutter disk; and

setting the shutter disk on a perimeter of the substrate support wherein center portions of the shutter disk and substrate support remain in a spaced-apart relation.